

INFORMATION DISCLOSURE CITATION
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Complete if Known

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|----------------------|-----------------------|
| Application Number | 10/553,573 |
| Filing Date | October 17, 2005 |
| First Named Inventor | Christian DUSSARRAT |
| Art Unit | 1715 |
| Examiner Name | Elizabeth A. Burkhart |

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| Sheet | 1 | of | 1 | Attorney Docket Number | Serie 6070 |
|-------|---|----|---|------------------------|------------|

U.S. PATENT DOCUMENTS

| Examiner Initials | Cite No. | Document Number | Publication Date | Name | Pages Column, Lines Where Relevant Passages or Relevant Figures Appear |
|-------------------|----------|-----------------|------------------|------------------|--|
| | A1 | US 5 932 286 | 8/03/1999 | BEINGLASS et al. | |
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|-------------------|----------|--|---|
| | C1 | PEREIRA, M.A. et al., "Silicon nitride deposited by ECR-CVD at room temperature for LOCOS isolation technology," Applied Surface Science 212-213 (2003), pp. 388-392 | |
| | C2 | YOTA, J. et al., "A comparative study on inductively-coupled plasma high-density plasma, plasma-enhanced, and low pressure chemical vapor deposition silicon nitride films," J. Vac. Sci. Technol. A 18(2), Mar/Apr 2000, pp. 372-376 | |
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|----------|-----------------|
| Examiner | Date Considered |
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